Convenient and Robust Route to Photoswitchable Hierarchical Liquid Crystal Polymer Stripes via Flow-Enabled Self-Assembly

Xiao Li,†‡ Bo Li,† Ming He,† Wei Wang,‡ Tianjie Wang,‡ Aurelia Wang,† Jiwoo Yu,‡ Zhonglin Wang,† Suck Won Hong,‡ Myunghwan Byun,∥ Shaoliang Lin,∥§ Haifeng Yu,∥§ and Zhiqun Lin*,†‡

†School of Materials Science and Engineering, Georgia Institute of Technology, Atlanta, Georgia 30332, United States
‡Department of Material Science and Engineering, and Key Laboratory of Polymer Chemistry and Physics of Ministry of Education, Peking University, Beijing 100871, P. R. China
§School of Materials Science and Engineering, East China University of Science and Technology, Shanghai 200237, P. R. China
∥Department of Cogno-Mechatronics Engineering, Department of Optics and Mechatronics Engineering, Pusan National University, Busan 46241, Republic of Korea
§Department of Advanced Materials Engineering, Keimyung University, Daegu 704-701, Republic of Korea

Supporting Information

ABSTRACT: Hierarchically arranged stripes of photoswitchable liquid crystal polymers (LCPs) containing azobenzene moieties were conveniently crafted via a flow-enabled self-assembly (FESA). Interestingly, by subjecting a drop of LCP solution to dry in a restricted geometry comprising two nearly parallel plates with a stationary upper plate and a movable lower plate that programmably traveled in a “stop-and-move” manner during the FESA process, photoswitchable LCP stripes were yielded, displaying two modes of deposition, namely, periodic primary stripes of large dimensions and regularly spaced secondary stripes of small dimensions situated between adjacent primary stripes (i.e., forming hierarchical LCP stripes). Notably, these hierarchical azobenzene moieties-containing stripes demonstrated sequential photoinduced reversible phase transition (i.e., photoswitching) due to the thickness difference between primary and secondary stripes. A UV light-induced expansion effect was observed on the LCP stripes. Clearly, such rapid creation of hierarchical stripes by FESA represents a robust means of organizing polymers, nanoparticles, colloids, DNA, etc. into complex yet ordered patterns over a large area in a simple and controllable manner for potential use in surface relief grating, photoactuators, photoswitchable devices, antifake labels, etc.

KEYWORDS: flow-enabled self-assembly, hierarchical structure, azo-containing liquid crystalline polymer, photoinduced phase transition, photoexpansion effect

INTRODUCTION

Azobenzene has been widely recognized as an appealing molecular switch for light-driven devices owing to the large yet reversible changes in its dipole moment and molecular shape that occur upon photoisomerization.1 Recently, several intriguing studies have centered on azo-containing LCPs, such as voxelated liquid crystalline elastomers,2 photoactuated microfluidics systems,3 and photoinduced wave propagation.4 Azobenzene moieties typically exist in a more stable trans-conformation as a rodlike molecule. The irradiation of azobenzene-containing molecule with UV light (365 nm) produces a large fraction of the bent cis-isomer, which reverts to the trans-state either thermally or upon exposure to visible light.5–7 For liquid crystal polymers (LCPs) containing azobenzene moieties, the rodlike trans-azo mesogens stabilize the liquid crystalline (LC) state, whereas the bent cis-azo units often destabilize the LC state. Such molecular-level rodlike-to-bent photoisomerization (and vice versa) and the associated photoinduced microscopic phase transition process (e.g., nematic LC-to-isotropic transition and vice versa) render azobenzene-containing LCPs for use in two-dimensional data storage and optical switch,8,9 surface-relief grating10,11 photoactuators,12–14 solar energy conversion,15,16 photoswitchable devices,17,18 and bistable photomodulation.19 The ability to craft micro- and nanostructures of LCP is of pivotal importance for these applications. However, it is notable that the implementation of azobenzene-containing LCPs for a broad range of applications noted above often involves the structuring of LCPs by direct laser writing, imprint, lithography, etc., which typically requires a high-cost operation (e.g., laser writing) or a tedious multistep procedure for pattern fabrication (e.g., lithography) and has low throughput.20 Clearly, a simple and
cost-effective technique that enables a rapid large-scale production of highly ordered azobenzene-containing LCPs patterns is highly desirable.

The evaporative self-assembly from a sessile drop containing nonvolatile solutes (e.g., coffee, nanoparticles, DNA, pigments, quantum dots, and polymers) represents an extremely simple route to a wide variety of intriguing and complex deposit patterns. However, irregular dissipative structures (e.g., randomly organized convection patterns and stochastically distributed multirings) are often yielded due to lack of control over the evaporative flux of solvent and the associated flow within the droplet, the interfacial interaction between solute and substrate, etc. Notably, recent advances in harnessing the solvent evaporation process by enforcing confined geometries over a droplet have offered great control of pattern formation, affording access to a rich array of regular structures and assemblies, including gradient concentric “coffee rings,” hierarchically ordered web, snake-skin-like structures, and two-dimensional grids. As light is a clean, easily accessible, nondestructive, and remotely controllable stimulus, the ability to assemble photoresponsive polymers into well-ordered structures by steering solvent evaporation in confined geometries may entail the speedy creation of desirable photoresponsive patterns.

Herein, we report on a convenient and rapid route to hierarchical azobenzene-containing LCP stripes over a large area via flow-enabled self-assembly (FESA). These hierarchical stripes can be reversibly photoswitched. First, the LCP solution was allowed to dry in a two-nearly-parallel-plate geometry, in which the upper plate was fixed, whereas the lower plate placed on a translational stage was programmatically traveled in a “stop-and-move” manner (i.e., a FESA process), yielding photo switchable LCP stripes that exhibited two forms of periodic LCP deposits. They are large-dimension primary stripes and small-dimension secondary stripes regularly situated between adjacent primary stripes (i.e., forming hierarchical stripes; and an array of nearly centimeter-scale stripes can be produced in less than 3 min). The size (width $w$ and height $h$) and the distance between two adjacent secondary stripes ($\lambda$) were largely dictated by a set of parameters, including the solution concentration ($c$), the moving speed of the lower plate ($v$), and the separation distance of two plates ($H$). Subsequently, the photoresponsive behavior of hierarchical LCP stripes was scrutinized by in situ polarized optical microscopy and UV−vis spectroscopy studies, revealing a nonsynchronized photoisomerization process arising from the thickness difference between primary and secondary stripes (i.e., secondary stripes disappear prior to primary stripes upon UV irradiation; primary stripes recover ahead of secondary stripes upon subsequent visible light exposure). Detailed exploration revealed that the stripes expanded when exposed to UV light and the expansion can be partially restored. In addition to LCP, hierarchical patterns were also produced by one-step FESA using other polymers.

**RESULTS AND DISCUSSION**

In our study, an LCP poly(6-(4-(4-ethoxyphenylazo)phenoxy)-hexyl methacrylate) ($\text{PM}_6\text{ABOC}_2$) (Figure 1a) was employed as nonvolatile solute for crafting photoswitchable hierarchical $\text{PM}_6\text{ABOC}_2$ stripes by FESA. $\text{PM}_6\text{ABOC}_2$ possesses a fast response to UV irradiation and efficient photoisomerization and has been widely used in photo actuators. Scheme S1 shows the synthetic route to $\text{PM}_6\text{ABOC}_2$. The success of synthesis was confirmed by $^1$H NMR (Figure S1). The LC temperature of $\text{PM}_6\text{ABOC}_2$ ranges from 94 to 148.5 °C upon heating (Figure 1b). The polarized optical micrograph for the sample annealed at 140 °C displayed a typical schlieren texture, indicating nematic LC phase (Figure 1c).

A drop of $\text{PM}_6\text{ABOC}_2$ toluene solution (e.g., concentration, $c = 2$ mg/mL) at room temperature was loaded in a two-nearly-parallel-plate geometry composed of a stationary upper plate (glass blade) and a moving lower plate (Si substrate for optical microscopy imaging in reflection mode or glass substrate for UV spectroscopy measurement on the photoisomerization process) separated by a certain distance $H$ (Figure 2a). In this study, toluene was chosen to craft well-ordered striped structures over other organic solvents (e.g., tetralhydrofuran (THF) or dimethylformamide (DMF)); the obtained patterns using the THF and DMF solutions are shown in Figure S2) due to the following several reasons: toluene is a good solvent for LCP and possesses a proper evaporation rate at room temperature and a proper contact angle with the substrate. In general, the contact angle ($\theta$) between the solution and the substrate is in the range of $0 < \theta < 90^\circ$ to ensure the wetting of the polymer solution. Figure S3 shows the contact angle of the LCP toluene solution on different substrates ($\theta_{\text{LCP/glass}} = 4.8^\circ$ and $\theta_{\text{LCP/Si wafer}} = 5.2^\circ$; no upper plate was applied).
The lower substrate was mounted on a computer-controlled translational stage that enables its stop-and-move mode motion during FESA of PM$_6$ABOC$_2$. First, the lower movable Si substrate was stationary for a short period of time $t = 1$ s (i.e., “stop”), during which the outward flow triggered by the evaporative loss of toluene transported PM$_6$ABOC$_2$ to the contact line (a well-known “coffee ring” effect)\(^{39}\), forming a thick PM$_6$ABOC$_2$ stripe (i.e., primary stripe). The Si substrate was then translated (i.e., “move”) at a certain moving speed $v$ (e.g., $v = 50$ $\mu$m/s); the meniscus (lower panel in Figure 2a) was stretched and the initial contact angle at the meniscus edge decreased to a critical value, at which the depinning force became larger than the pinning force,\(^{41}\) leading to the jump of the contact line to new position at which the initial contact angle was resumed (i.e., “slip”) and thus forming a new PM$_6$ABOC$_2$ stripe (i.e., secondary stripe). The repetitive stick-and-slip cycles of the three-phase contact line yielded a set of periodic secondary stripes until the Si substrate stopped at a new position (i.e., a subsequent stop) (Figure 2a) for the same $t = 1$ s, where a new primary stripe formed. We define the typical distance between two adjacent primary stripes formed at the stop locations enabled by using the translation stage as $\lambda_p$. Accordingly, the characteristic distance between two neighboring secondary stripes at the “stick” locations formed during the movement of the lower Si substrate due to the stick-and-slip motion of the contact line was referred to as $\lambda_S$. A representative optical micrograph of hierarchical PM$_6$ABOC$_2$ stripes with high regularity formed via FESA by moving the lower Si substrate in a stop-and-move mode mode (forming primary periodic stripes) in conjunction with the stick-and-slip motion of the contact line (forming periodic secondary stripes within two adjacent primary stripes) is shown in Figure 2b. Clearly, the dimension of primary stripes is larger than that of secondary stripes, which was further substantiated by the Raman measurement.\(^{42}\) As shown in Figure 2c, the most notable peaks of azobenzene-containing PM$_6$ABOC$_2$ appeared at 1194 $\text{cm}^{-1}$ (C–N symmetric stretch), 1241 $\text{cm}^{-1}$ for C–N symmetric bending, and 1506 $\text{cm}^{-1}$ for C–C symmetric stretching.\(^{43\text{a–d}}\) Thus, the N=N symmetric stretch at 1458 $\text{cm}^{-1}$ was chosen as a characteristic peak of PM$_6$ABOC$_2$ for the Raman line scanning. Figure 2d displays the Raman line scanning at 1458 $\text{cm}^{-1}$ over a distance of 140 $\mu$m (the corresponding optical micrograph is shown as an inset), clearly revealing a well-defined hierarchical structure composed of 2 higher and wider primary stripes with $\lambda_p$ of 100 $\mu$m and 11 uniformly arranged lower and narrower secondary stripes with $\lambda_S$ of $\sim$100/12 = 8.3 $\mu$m. Two primary stripes exhibited a much stronger Raman signal, demonstrating the obvious height difference between primary and secondary stripes. Furthermore, the comparison of the intense Raman signal on the stripes and zero counts over the region between secondary stripes confirmed that there was no PM$_6$ABOC$_2$ deposited between secondary stripes.\(^{46}\)

Notably, hierarchical stripes over a large area can be readily and rapidly created simply by one-step FESA (Movie S1). An array of nearly centimeter-scale stripes can be produced in less...
than 3 min. The drying 6 μL PM6ABOC2 toluene solution yielded hierarchical stripes over a surface area of 0.8 × 0.8 cm², which is governed by the size of upper stationary glass blade used in the FESA process (0.8 × 0.8 cm² in this study) as well as the volume of the PM6ABOC2 toluene solution. Obviously, by employing a larger-sized upper plate and continuously supplying the FESA apparatus with solution, hierarchical stripes deposited over an even larger surface area can be conveniently achieved.

It is noteworthy that \( \lambda_p \) and the size of primary stripes (i.e., width \( w_p \) and height \( h_p \)) can be easily tailored by altering the distance that the lower Si substrate travels and the time the Si substrate stops. Unless otherwise specified, in our study, \( \lambda_p \) of 50 and 100 μm was deliberately obtained for AFM imaging and other characterizations (e.g., optical microscopy imaging, etc.), respectively, and the time for the lower Si substrate to stop was set as 1 s. The undulation along the primary stripe was seen, which may be due to the unfavorable interaction between PM6ABOC2 and the Si substrate.24,47

As primary stripes were yielded simply by modulating the distance that the lower Si substrate traveled and the stop time it experienced, the creation of primary stripes is straightforward and easily controlled. Thus, we turn our attention to explore the influence of experimental conditions, including the solution concentration \( (c) \) and the moving speed of the lower substrate \( (v) \) on the formation of secondary stripes. Figure 3 compares AFM height images of three samples obtained via FESA of PM6ABOC2 toluene solution at different \( c \) and \( v \), while keeping other parameters fixed (i.e., \( \lambda_p = 50 \) μm and the separation distance between upper and lower plates \( H = 400 \) μm). At low \( c \) (\( c = 0.5 \) mg/mL), no secondary stripes were observed when performing FESA of PM6ABOC2 toluene solution at \( v = 50 \) μm/s (Figure 3a). Clearly, the experimental condition where \( c = 2 \) mg/mL and \( v = 50 \) μm/s rendered the crafting of an array of periodic secondary stripes. On the other hand, FESA of PM6ABOC2 toluene solution (\( c = 2 \) mg/mL) at higher \( v = 100 \) μm/s also failed to yield secondary stripes. Interestingly, the formation of secondary stripes was found to be independent of the existence of primary stripes, that is, secondary stripes can still be produced at proper moving velocity \( v \) and solution concentration \( c \) (Figure 3d) by continuously moving the lower Si substrate mounted on the translational stage (i.e., without stop of the Si substrate, namely, with no primary stripes formed).

A further scrutiny of the \( c \) and \( v \) spaces revealed that the formation of periodic secondary stripes depended heavily on \( c \) and \( v \). Figure 3e shows the parameters within the shadow area resulted in the regular secondary stripe arrays. Notably, a minimal critical concentration \( c_{\text{critical,min}} \) of 0.2 mg/mL that hierarchical stripes can form existed. Below \( c_{\text{critical,min}} \), no
secondary stripes were observed, as there was not enough polymers to be pinned at the contact line to form stripes. In the area above the shadow, where \( v \) is faster and \( c \) is lower, secondary stripes also failed to be produced. Below the shadow area, where \( v \) is slower and \( c \) is higher, relatively irregular patterns were predominant. From this 2D \( c-v \) map, the critical moving speed (i.e., \( v_{\text{critical}} \)) at a certain concentration and the critical concentration (i.e., \( c_{\text{critical}} \)) at a fixed moving speed can also be identified in the shadow area (e.g., at a certain \( c = 2 \) mg/mL, critical speeds for forming periodic secondary stripe arrays were \( v_{\text{max}} = 100 \) \( \mu \)m/s and \( v_{\text{min}} = 30 \) \( \mu \)m/s, respectively). \(^{28} \) A slower moving speed enabled sufficient pinning time yet shorter characteristic distance between two adjacent secondary stripes \( \lambda_S \). For example, at \( v = 100 \) \( \mu \)m/s, only 0.5 s was needed for the lower substrate to move from one primary stripe deposit position to the next location (i.e., traveling a distance of 50 \( \mu \)m). However, when \( v \) was reduced to 10 \( \mu \)m/s, it took 5 s to reach the next stop position at the same traveling distance of 50 \( \mu \)m, which afforded much longer time for the polymer to undergo stick-and-slip cycles (i.e., pinning and depinning cycles) within two primary stripes, thus leading to the formation of more densely populated secondary arrays, that is, a shortened \( \lambda_S \).

It has been reported that a critical moving distance (and thus a minimum spacing between two adjacent stripes \( \lambda_{\text{min}} \)) is required for the contact line pinning and depinning process to yield a highly ordered pattern. \(^{25} \) In this study, when \( \lambda_S \) was shorter than \( \lambda_{S,\text{min}} \) (i.e., \( \lambda_S < \lambda_{S,\text{min}} \)), a relatively irregular pattern formed. Once the moving speed of the lower Si substrate was slow enough (e.g., \( v = 10 \) \( \mu \)m/s for 2 mg/mL solution) to induce a smaller \( \lambda_S \) than \( \lambda_{S,\text{min}} \) secondary stripes became relatively irregular. For the 2 mg/mL solution, as \( v \) increased from 40 to 80 \( \mu \)m/s, the number of secondary stripes \( N \) within a 50 \( \mu \)m distance defined by two adjacent primary stripes decreased from six to three and \( \lambda_S \) increased from 5.84 to 9.71 \( \mu \)m (Figure 4e). At the same time, both \( w_S \) and \( h_S \) of secondary stripes increased as a result of the decreased \( N \) (Figure 4f). \( w_S \) increased from 3.44 to 4.03 \( \mu \)m, and \( h_S \) increased from 25 to 37 nm. Compared with higher concentration, at a certain moving speed of the lower Si substrate, less PM6ABOC\(_2\) was deposited to create local surface roughness to pin the contact line at lower concentration. Therefore, secondary stripes were thinner. As \( c \) increased from 1 to 2 mg/mL, \( N \) decreased from seven to four and \( \lambda_S \) increased from 5.66 to 7.70 \( \mu \)m (Figure S4e); meanwhile, \( w_S \) increased from 3.20 to 4.38 \( \mu \)m and \( h_S \) increased from 19 to 40 nm (Figure S4f).

It is worth noting that \( \lambda_S \), \( w_S \), and \( h_S \) of secondary stripes can also be tuned by adjusting the separation distance \( H \) between the upper glass blade and the lower Si substrate (Figure S5).\(^{28} \)At the same \( c \) and \( v \) (i.e., \( c = 2 \) mg/mL and \( v = 50 \) \( \mu \)m/s), a smaller \( H \) entailed more yet thinner secondary stripes. As \( H \) decreased from 1000 to 100 \( \mu \)m, \( N \) increased from three to six, \( \lambda_S \) decreased from 10.35 to 4.94 \( \mu \)m, and \( w_S \) and \( h_S \) decreased from 3.68 to 2.82 \( \mu \)m and from 50 to 25 nm, respectively. A decreased \( H \) slowed down the evaporation rate of solvent, thus leading to a reduction in the meniscus moving speed.\(^{23,49} \) Consequently, the contact line receded over a shorter distance before the formation of a new stripe, resulting in a higher deposition density of secondary stripes. In other words, the reduced evaporative loss of toluene caused the solutes to be deposited less at contact line (i.e., smaller \( h_S \) and \( w_S \)) and jumped less to the next position where it was pinned again (i.e., shorter \( \lambda_S \)).

As noted above, azobenzene-containing LCPs undergo photoinduced microscopic phase transition due to molecular-level photoisomerization between cis- and trans- conformations upon exposure to light. Compared to other external stimuli, light can be rapidly employed and delivered remotely and
instantaneously to the targeted location in a noninvasive manner. In this context, the photoresponsive behavior of crafted hierarchical stripes composed of azobenzene moieties-containing PM6ABOC2 was explored. The PM6ABOC2 stripes prepared from $c = 2$ mg/mL and $v = 50 \mu m/s$ condition were first annealed at 140 °C in a vacuum oven for 12 h to obtain alignment of LC mesogens and then cooled down to room temperature to retain their nematic LC phase. After annealing, the LC texture was clearly observed under a polarized optical microscope (Figure 5a). Upon rotation by 45° and 90° under POM, no obvious brightness change was observed (Figure S6), indicating the multidomain nematic phase, that is, the mesogens are not oriented in a certain direction. As trans- mesogens are rodlike and can be maintained in nematic LC phase, whereas bent cis- mesogens destroy the ordered LC phase, an isothermal nematic-to-isotropic phase transition was thus induced upon UV irradiation (Figure 5j). As UV irradiation at room temperature continued, LC textures gradually disappeared owing to the photoinduced nematic-to-isotropic phase transition (Figure 5b–d). An in situ polarized optical microscope observation demonstrated that secondary stripes disappeared first, followed by the extinction of primary stripes. Within a 30 s UV irradiation, secondary stripes vanished first due to lower $h_{op}$ whereas primary stripes can still be seen (Figure 5b). A further UV exposure for 300 s resulted in the transition of thicker nematic primary stripes into their isotropic phase. This can be easily understood due to the height difference between primary and secondary stripes. Subsequently, hierarchical stripes in nematic phase were recovered upon visible light irradiation. After a 300 s visible light irradiation, primary and secondary stripes nearly completely reappeared (Figure 5e–h), which can be attributed to the cis-to-trans transition under visible light irradiation (Figure 5j), demonstrating a photoswitching characteristic of hierarchical PM6ABOC2 stripes.

In addition to hierarchical stripes formed on the Si substrate, the molecular-level trans—cis photoisomerization behavior was further monitored by UV–vis spectroscopy on samples after being exposed to UV irradiation for different times. These samples were prepared on a transparent glass substrate by FESA of the PM6ABOC2 toluene solution. A series of UV–vis absorption curves obtained after exposing to UV for different times (0, 5, 10, 30, 60, 120, 180, 240, and 300 s) are shown in Figure 5i. The absorption peak of trans- mesogens at 358 nm represents a $\pi-\pi^*$ excitation of the azobenzene group, whereas the absorption peak of cis- isomers at 452 nm indicates an $n-\pi^*$ transition. Prior to exposure to UV light, the $\pi-\pi^*$ excitation peak at 358 nm was prominent and the $n-\pi^*$ transition peak at 452 nm was almost invisible, signifying a trans- rich state. As the UV irradiation time progressed, the $\pi-\pi^*$ peak at 358 nm dropped and gradually shifted to 317 nm. In the meantime, the $n-\pi^*$ transition at 452 nm emerged and...
gradually increased, suggesting the transition from trans-mesogens to cis-isomers.

The height of a certain secondary stripe ($h_S$) before UV light irradiation as well as with UV (365 nm, 100 mw/cm$^2$)
irradiation for 300 s followed by visible light irradiation (460 nm, 100 mw/cm²) for 300 s (Figure 6a–c) was measured. The initial height of a secondary stripe is 57.3 nm, the UV light irradiation induced the height photoexpansion to 59.6 nm, representing a 4% expansion. The subsequent visible light irradiation can only partially recover the height to 58.3 nm (a 1.7% expansion compared to that of the initial height; Figure 6d). The repeated UV–vis light irradiation cycles resulted in a reversible expansion upon the UV light exposure and a recovery with the visible light exposure (Figure 6e). We note that the similar phenomenon has been reported in the literature.39 The photoexpansion effect can be attributed to the requirement of more free volume due to the trans–cis conformational change. The first-time expansion is composed of the volume expansion of cis-chromophore compared with that of trans- and the expansion of the polymer matrix. The trans–cis–trans conformational change contributed to the reversible expansion, whereas the increase of free volume trapped in the polymer matrix cannot be fully recovered to the initial height owing to the high Tg of LCP (95 °C) at room temperature. Interestingly, the FESA strategy is viable and robust; in addition to hierarchical stripes produced using LCP, hierarchical stripes of other polymers can also be conveniently crafted. Figure 7a,b shows hierarchical stripes of polystyrene (PS) and poly(methyl methacrylate) (PMMA) formed in the same manner as PM6ABOC2. More intriguingly, by judiciously manipulating the typical distance of primary stripes λp, a gradient hierarchical structure can also be achieved (Figure 7c). As λp decreased from 140–100 to 80–60 μm, the number of secondary stripes within two primary stripes changed accordingly from 14–10 to 7–5 (Figure 7c). Such a gradient hierarchical pattern may find potential applications in encoding and cell motility study.

CONCLUSIONS

In summary, hierarchical photoswitchable stripes consisting of smaller-sized secondary stripes situated between larger-sized primary stripes were, for the first time, exquisitely crafted over large areas by flow-enabled self-assembly of azobenzene-containing LCP in a two-nearly-parallel-plate geometry that renders the control over solvent evaporation. The primary and secondary stripes were yielded as a direct consequence of repetitive stop-and-move mode motion of the lower substrate in the two-nearly-parallel-plate geometry and stick-and-slip cycle of the contact line, respectively. The moving speed of the lower substrate and solution concentration exerted a profound influence on the formation of secondary stripes. A relatively slow moving speed and higher solution concentration favored the creation of periodic secondary stripes. The separation distance between the upper blade and lower substrate also impacted the dimension of secondary stripes. The hierarchical stripes displayed a microscopic reversible photoinduced LC-to-isotropic phase transition due to the molecular-level trans-to-cis photoisomerization of azobenzene moieties. A UV light-induced photoexpansion effect was observed on the LCP stripes, which can be partially recovered after visible light irradiation. The height difference between primary and secondary stripes conferred the phase transition of these hierarchical stripes to occur sequentially, which may be useful for photoswitchable materials and devices. Furthermore, hierarchical stripes were also achieved in other polymers such as PS and PMMA. A gradient hierarchical PS stripe was also constructed. As such, FESA may provide a convenient and robust means to arrange a wide range of building blocks, including polymers, colloids, nanocrystals, graphene, etc., into complex patterns over a large area with exquisite control over the periodicity. They may find application in solar cells as the light trapping layer to improve light-harvesting efficiency,56 triboelectric nanogenerators by increasing the effective contact area and thus the output voltage and current,57 cell motility and adhesion, and cell mechanotransduction.58,59

EXPERIMENTAL SECTION

Synthesis of Liquid Crystalline Polymer Poly(6-(4-(4-ethoxyphenylazo)phenoxy)-hexyl methacrylate) (PM6ABOC2).

Synthesis of Monomer M6ABOC1. The monomer M6ABOC1 was prepared by a three-step procedure according to the literature.50 First, 4-ethoxy-4′-hydroxyazobenzene (compound 1 in Scheme S1) was obtained via a diazo coupling reaction between 4-ethoxylamine and phenol in the presence of sodium nitrate and hydrochloric acid. Second, the 4-ethoxy-4′-hydroxyazobenzene (compound 2 in Scheme S1) was mixed together with 6-chloro-1-hexanol, potassium carbonate, and a trace amount of potassium iodide in ethanol and then refluxed for 12 h to produce 4-ethoxy-4-(6-hydroxy hexyloxy). Finally, the monomer M6ABOC1 was produced by the esterification reaction between 4-ethoxy-4′(6-hydroxy hexyloxy) and methacryloyl. The monomer was purified by recrystallization in methanol.

Synthesis of PM6ABOC2. Liquid crystal polymer poly(6-(4-(4-ethoxyphenylazo)phenoxy)-hexyl methacrylate) (PM6ABOC2) was synthesized by free radical polymerization of M6ABOC1 using 2,2-azobisisobutyronitrile (AIBN) as initiators at 70 °C in anhydrous DMF and was then purified by precipitation in methanol three times. The molecular weight of the obtained polymer is Mn = 24k (polydispersity index = 1.61). The 1H NMR spectrum of the purified polymer is shown in Figure S1.

Flow-Enabled Self-Assembly of Photoswitchable PM6ABOC2 Stripes. After the flow-enabled self-assembly process, PM6ABOC2 stripes were annealed at 140 °C for 12 h in vacuum and cooled down to room temperature to keep their LC phase. The resulting stripes with LC texture were observed under a polarized optical microscope (POM). Visible light photoirradiation process was performed with a 100 W mercury lamp, and the UV light was obtained with the same light source using a 365 nm UV filter mounted on an optical microscope. The LC-textured stripes were exposed to 365 nm UV light to observe the phase transition.

Characterizations. The optical image and LC texture of PM6ABOC2 stripes were obtained by an optical microscope (Olympus BX51). The AFM image was conducted in tapping mode (Bruker Dimension Icon 3100), and the force constant of the probe is 40 N/m. The Raman measurement were performed using laser, with the excitation wavelength of 532 nm and power of 25 mW (Renishaw, in-Via). The photoisomerization behavior was examined by a Shimadzu UV-2600 spectrometer. A differential scanning calorimetry (DSC8000, PerkinElmer) was used to determine thermal properties of LCP.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acsami.7b16001.

Synthetic process, 1H NMR, DSC curve, POM image, and the Raman spectrum of PM6ABOC2 liquid crystalline polymer; influence of the concentration (c)